

## Electrodeposition of n-type Cuprous Oxide Thin Films

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Cuprous oxide ( $\text{Cu}_2\text{O}$ ) is an attractive material for solar energy applications because it is low cost, non toxic and has a direct band gap of 2 eV. It has been well established that  $\text{Cu}_2\text{O}$  is generally a p-type semiconductor material due to the Cu ion vacancies exist in the crystal lattice<sup>1,2</sup>. Among the various methods available for growing  $\text{Cu}_2\text{O}$  films, electrodeposition is attractive because it provides a low cost method for growing thin films for solar energy applications<sup>4,8</sup>. Moreover, electrodeposition of  $\text{Cu}_2\text{O}$  provides the possibility of depositing cuprous oxide thin films on conducting substrates resulting n-type photoresponse in solar cell devices<sup>4,9,10</sup>. Indeed, electrodeposition of  $\text{Cu}_2\text{O}$  in high pH aqueous depositing baths produces p-type conducting films. However, by maintaining the pH values in the range of 5.5 to 7.5 of the depositing bath,  $\text{Cu}_2\text{O}$  thin films can be potentiostatically electrodeposited in a potential domain of about 300mV, as shown in Fig. 1. Single phase  $\text{Cu}_2\text{O}$  polycrystalline films can be obtained in this potential domain and at more negative depositing potentials co-deposition of Cu is resulted. Photoresponse of a  $\text{Cu}_2\text{O}$  film electrode in a photoelectrochemical cell is shown in Fig. 2, where the photocurrent signal is n-type. This n-type behavior and the quality of the  $\text{Cu}_2\text{O}$  films produced by this technique will be presented using CV, SEM, XRD, EDX, XPS and XRF data. Further, the evidence of the existence of oxygen vacancies in the electrodeposited n-type  $\text{Cu}_2\text{O}$  films is presented. Possibility of using these n-type films in low cost solar cell devices is demonstrated by establishing the n- $\text{Cu}_2\text{O}$ /p- $\text{Cu}_x\text{S}$  junction by sulphiding  $\text{Cu}_2\text{O}$  thin films<sup>11</sup> and the spectral response of the ITO/n- $\text{Cu}_2\text{O}$ /p- $\text{Cu}_x\text{S}$ /Al structure is shown in Fig. 3. Implications of the results presented for low cost solar cell devices will be discussed.

1. J. Bloem, *Philips Res. Reports.*, **13**,167 (1958).
2. Pollack, G.P.; Trivich, D, *J. Appl. Phys.*, **46**,163 (1975).
3. R.S.Toth, R.Kilkson, and D.Trivich, *Phys. Rev.*, **122**, 482 (1961).
4. W. Siripala, J.R.P Jayakody. *Sol. Energy Mater.* **14**,23(1986).
5. A.E Rakshami, *Solid State Electron.*, **29**,7 (1986).
6. L.D.R.D. Perera, W. Siripala and K.T.L. De Silva, *J. Nat. Sci. Coun., Sri Lanka*, **24** (4), 299 (1996).
7. T.Mahalingam, J.S. Chitra, S.Rajendran and P.J. Sebastian, *Semicon.Sci.Technol.*, **17**, 565 (2002).
8. R.N Briskman, *Sol. Energy Mater. Sol. Cells* **27**,361 (1992).
9. W Siripala,L.D.R.D Perera, K.T.L De Silva, J.K.D.S,Jayanetti, I.M Dharmadasa. *Sol. Energy Mater. Sol. Cells*, **44**,251(1996).
10. W.Siripala, *J.Natu. Sci. Coun. Sri Lanka* **23**(1), 49 (1995).
11. R.P.Wijesundara,L.D.R.Perera, K.D.Jayasuriya, W.Siripala, K.T.L. De Silva, A.P.Saumanthilleke, I.M. Dharmadasa, *Sol. Energy Mater. Sol. Cells* **61**, 77 (2000).

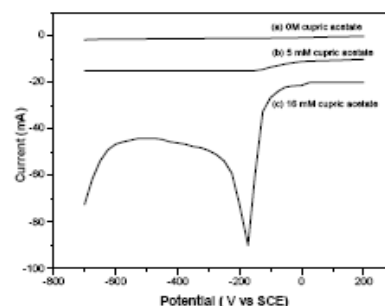


Fig.1 Current-voltage characteristics of a platinum electrode in a three electrode electrochemical cell containing 0.1 M sodium acetate and cupric acetate concentrations of (a) zero (b) 0.5 mM and (c) 16 mM.

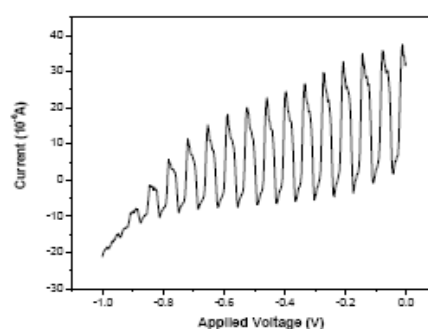


Fig. 2 Current voltage characteristics of a  $\text{Cu}_2\text{O}$  thin film electrode in a PEC cell containing 0.1 M sodium acetate solution, under chopped light illumination.

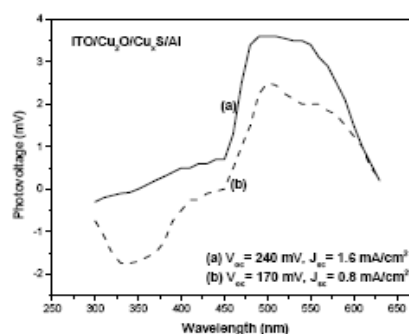


Fig.3 Spectral responses of ITO/ $\text{Cu}_2\text{O}$ / $\text{Cu}_x\text{S}$ /Al solar cell structures producing different solar cell outputs (a)  $V_{oc}$  =240 mV,  $J_{sc}$  = 1.6 mA/cm<sup>2</sup> and (b)  $V_{oc}$  =170 mV,  $J_{sc}$  = 0.8 mA/cm<sup>2</sup>.